

Serial No.: 10/667,603



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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of

Docket No.: FIS920030188US1

Dureseti Chidambarao, et al.

Serial No.: 10/667,603

Group Art Unit: 2829

Filed: September 23, 2003

Examiner: Geyer, Scott B.

For: **STRAINED SILICON ON RELAXED SIGE FILM WITH UNIFORM MISFIT
DISLOCATION DENSITY**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

Sir:

In response to the Restriction Requirement dated September 9, 2004, Applicants elect Group I, claims 1-16, without traverse.

Applicants believe that no extensions of time or fees for net addition of claims are required at this time. However, if additional extensions of time are necessary to prevent abandonment of this application, then such extensions of time are hereby petitioned under 37 C.F.R. §1.136(a), and any fees required therefor (including fees for net addition of claims) are hereby authorized to be charged to International Business Machines Corporation's deposit Account No. 09-0458.